

Call for Papers

The 9th International Symposium on Advanced Science and Technology of Silicon and Related Materials



6 (Tue) – 9 (Fri) October, 2026

CHÂTERAISÉ HOTEL NAGANO (Nagano, JAPAN)



The International Symposium on Advanced Science and Technology of Silicon and Related Materials is held every four years to promote the development of silicon and related technologies. The 9th symposium, scheduled for October 6-9, 2026 in Nagano, will be held in a single session format to enable maximum interaction between researchers in various technical fields.

SCIENTIFIC PROGRAM

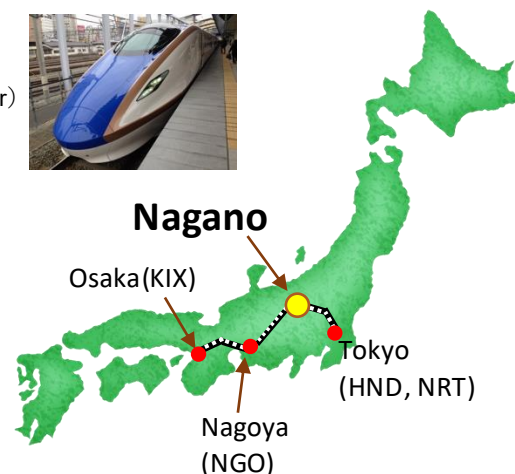
- Crystal Growth and Wafer Technology
- Defects and Impurities, Advanced Characterization Technology
- Power Devices and Their Materials
- Materials Informatics, Process Informatics
- Activities of LSTC in Japan (Leading-edge Semiconductor Technology Center)
<https://www.lstc.jp/english/>

Abstract submission (for poster presentation)
May 26 – August 7, 2026

Nagano is a highland city surrounding many mountains in the central region of Japan, in where The Olympic Winter Games were held in 1998. Nagano can be accessed from Tokyo by bullet train in about 2 hours. Nagano has rich in nature and you can enjoy delicious local cuisine and "sake" with beautiful scenery in autumn.



VENUE:
CHÂTERAISÉ
HOTEL
→
NAGANO Sta.
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